| Search Notes | | | | |
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| Application/Control No. | Applicant(s)/Patent under Reexamination |
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| 10/660,306 | LIU, HEBEN |
| Examiner | Art Unit |
| Christopher K. Agrawal | 3726 |

| SEARCHED | | | | |
|----------|----------|-----------|----------|--|
| Class | Subclass | Date | Examiner | |
| 29 | 890.032 | 1/11/2006 | СКА | |
| | 890.046 | 1/11/2006 | CKA | |
| | 890.05 | 1/11/2006 | CKA | |
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| SEARCH NO (INCLUDING SEARCH | |) |
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| | DATE | EXMR |
| see attached EAST workspace for search history | 1/11/2006 | СКА |
| consulted Examiner Compton regarding field of search | 1/11/2006 | СКА |
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